Supporting Information

Ce-Doped Nanorod-like NiFe-MOF with Coordination Substitution

Based on In-situ Co-Doping Method for Enhancing the Oxygen

Evolution Reaction.

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Experimental Section

1. Chemicals

Nickel(II) nitrate (Ni(NO₃)₂·6H₂O, AR, \geq 98.0%), potassium hydroxide (KOH, GR, \geq 85%), 1,4-terephthalic acid (1,4-H₂BDC, \geq 99.0%) were all produced by Sinopharm Chemical Reagent Co., Ltd. Ferric(III) chloride (FeCl₃·6H₂O, 99%), cerium(III) nitrate (Ce(NO₃)₃·6H₂O, 99%), N, N-dimethylacetamide (DMAC, 99.0%) were all produced by MACKLIN Chemical Reagent Co., Ltd. Absolute ethanol (C₂H₅OH, AR, \geq 99.7%) was produced by Ling Feng Chemical Reagent Co., Ltd. Nafion (C₁₀H₇OH, 5 *wt*.%) was produced by Sigma-Aldrich Chemical Reagent Co., Ltd. All aqueous solutions were prepared using deionized water.

2. Preparation

2.1. Synthesis of Fe-MIL-53

1,4-H₂BDC (0.1 mmol, 16.6 mg) and FeCl₃·6H₂O (0.1 mmol, 27.0 mg) were added to 12 mL of DMAC in a Teflon vessel (20 mL). The mixture was stirred to form a yellow clear solution, transferred to a stainless-steel autoclave and then heated at 150 °C for 3 h. When cooled to room temperature, the products were collected via centrifugation and washed with ethanol and water for three times.

2.2. Synthesis of Ni_{1.6}Fe-MIL-53

The preparation process of Ni_{1.6}Fe-MIL-53 was the same as that of Fe-MIL-53, except that Ni(NO₃)₂·6H₂O (0.16 mmol, 46.6 mg) needs to be added to the solution at the beginning.

2.3. Synthesis of CeNi_{1.6}Fe-MIL-53

The preparation process of CeNi_{1.6}Fe-MIL-53 was the same as that of Ni_{1.6}Fe-MIL-53, except that Ce(NO₃)₃·6H₂O (0.1 mmol, 43.4 mg) needs to be added to the solution at the beginning.

2.4. Synthesis of Ce@Ni_{1.6}Fe-MIL-53

The first preparation process of Ce@Ni_{1.6}Fe-MIL-53 was the same as that of Ni_{1.6}Fe-MIL-53. Then the products were dispersed in ethanol, then Ce(NO₃)₃·6H₂O (0.1 mmol, 43.4 mg) was added into the above solvent, after ultrasonic dispersion, the mixture was remained reaction for 15 min at room temperature. The products were collected, washed with ethanol and water for three times, dried, and stored at room temperature.

2.5. Synthesis of $Ce_xNi_{1.6}Fe-MIL-53$ (x = 0.6, 0.8, 1.2, 1.4)

The preparation process of $Ce_xNi_{1.6}Fe$ -MIL-53s was the same as that of $CeNi_{1.6}Fe$ -MIL-53, except using different molar ratios of $Ce(NO_3)_3 \cdot 6H_2O$ (0.06 mmol, 0.08 mmol, 0.12 mmol and 0.14 mmol) at the beginning.

2.6. Synthesis of $Ce_x@Ni_{1.6}Fe-MIL-53$ (x = 0.6, 0.8, 1.2, 1.4)

The preparation process of $Ce_x@Ni_{1.6}Fe-MIL-53$ was the same as that of $Ce@Ni_{1.6}Fe-MIL-53$, except using different molar ratios of $Ce(NO_3)_3 \cdot 6H_2O$ (0.06 mmol, 0.08 mmol, 0.12 mmol and 0.14 mmol) at the second step.

3. Characterizations

Images were obtained using a JEM-2100 transmission electron microscope (TEM) produced by Hitachi in Japan. The materials' morphology and energy spectrum were analyzed using a Hitachi cold field emission scanning electron microscope (SEM) model S-400, which was connected with an energy dispersive spectrometer (EDS). The Talos field emission TEM was used to examine pictures of high-resolution TEM (HRTEM), high angle annular dark field scanning TEM (HAADF-STEM), and elemental mapping. Powder X-ray diffraction (XRD) patterns were analyzed using a Bruker D8 Advance diffractometer at 40 kV and 40 mA, using Cu K α radiation (λ =1.5418 Å). X-ray photoelectron spectroscopy (XPS) data were collected using an EXCALAB 250 XI spectrometer with monochromatic Al K α radiation as the excitation source. The C 1s peak binding energy (248.5 eV) was calibrated to ensure reliable results.

4. Electrochemical Tests

All electrochemical tests were performed on a CHI 660E electrochemical workstation produced by Chen Hua in China, using a three-electrode system in 1.0 M KOH solution. To create the electrochemical ink for testing, 2 mg of catalyst and 1 mg of conductive carbon black were distributed in 1 mL of ethanol, along with 10 μ L of Nafion solution, and sonicated until completely dispersed. The ink was then dropped onto a polished glassy carbon (GC) electrode with a diameter of 5 mm and left to dry naturally at ambient temperature.

GC electrode was employed as the working electrode, carbon electrode was used as the counter electrode, while Hg/HgO(saturated KOH) electrode was utilized as the reference electrode. Linear sweep voltammetry (LSV) curves were collected at a scan rate of 5 mV s⁻¹. Corrected *IR* loss for all LSV curves. CP curve was operated at *j* = 10 mA cm⁻² under the same conditions. The measured potential was corrected to RHE according to the formula: $E_{RHE} = E_{Hg/HgO} + 0.244V + 0.0592V \times pH$. Calculated the overpotential (η) according to the formula: $\eta = E_{RHE} - 1.23V$.

ECSA was determined using the electrochemical double-layer capacitance (C_{dl})

based on the formula: $ECSA = C_{dl}/C_s$ ($C_s = 0.04 \text{ mF cm}^{-2}$)¹, which calculated by testing the CV at different scan rates (v = 10 ~ 50 mV s⁻¹) in $\varphi = 1.0 \sim 1.1 \text{ V vs RHE}$, based on the formula $C_{dl} = j_c/v$, where j_c is the charge current (mA cm⁻²), and v is the scan rate (mV s⁻¹).

The turnover frequency (TOF) of OER was calculated by the following equation:

$$TOF = \frac{j \times F}{16 \times RT \times C_{dl}}$$

where *j* is the current density at $\eta = 250 \text{ mV} (\text{mA cm}^{-2})$, $F = 96580 \text{ C mol}^{-1}$, $R = 8.314 \text{ J mol}^{-1} \text{ K}^{-1}$, *T* is the absolute temperature (298 K), C_{dl} is the electrochemical double-layer capacitance (mF cm}^{-2}).

EIS tests were recorded at 5 mV from 0.01 Hz to 10 kHz.

A two-electrode design was used in the overall water splitting examination. The GC electrode served as the anode, with commercial Pt/C as the cathode.

Proof Process Details of turnover frequency (TOF).

The turnover frequency (TOF) of OER was calculated by the following equation:

$$TOF = \frac{i}{n \times F \times N_{site}} = \frac{j \times A_{geo}}{n \times F \times N_{site}} \mathsf{L}$$
(1)

where *j* is the current density at an overpotential of 250 mV, A_{geo} is the geometric area of the electrode, *n* is the number of electrons involved (4 for OER), *F* is the Faraday constant (96580 C/mol), and N_{site} is the total number of metal sites on the electrode determined.

In above mentioned equation the total number of metal sites (N_{site}) can be determined from the value of slope (acquired from scan rate v vs current i_c)².

$$slope = \frac{a^2 \times F^2 \times N_{site}}{4RT} = i_c / \nu = C_{dl} \times A_{geo}$$

The equation can be transformed as below:

$$N_{site} = C_{dl} \times A_{geo} \times \frac{4RT}{a^2 \times F^2} L \quad (2)$$

Based on the equation (1) and (2), *TOF* can be calculated as below:

$$TOF = \frac{j \times A_{geo}}{n \times F \times N_{site}} = \frac{j \times A_{geo}}{4 \times F \times \left(C_{dl} \times A_{geo} \times \frac{4RT}{a^2 \times F^2}\right)} = \frac{j}{C_{dl} \times \frac{16RT}{a^2 \times F}} = \frac{j \times F \times a^2}{16 \times RT \times C_{dl}}$$

where *j* is the current density at an overpotential of 250 mV (mA cm⁻²), *F* is the Faraday constant (96580 C/mol), *R* is the universal gas constant (8.314 J mol⁻¹ K⁻¹), *T* is the absolute temperature (298 K), C_{dl} is the electrochemical double-layer capacitance (mF cm⁻²), a^2 is the number of electron intricate in rate determining step (for oxidation process, suppose $a^2 = 1$).

$$\therefore TOF = \frac{j \times F}{16 \times RT \times C_{dl}}$$

Supporting Figures and Tables.



Fig S1. TEM images of (a) Fe-MIL-53 and (b) Ni_{1.6}Fe-MIL-53. Scale bars are: (a) 200 nm and (b) 500 nm resolutions.



Fig S2. TEM images of (a) CeNi_{1.6}Fe-MIL-53 and (b) Ce@Ni_{1.6}Fe-MIL-53. (c) SEM image of Ce_{1.0}Ni_{1.6}Fe-MIL-53. Scale bars are: (a, b) 200 nm and (c) 2.00 μ m resolutions.



Fig S3. (a) HRTEM images of Ce@NiFe-MOF-5(Insert: Images resulting from fast

Fourier transform of HRTEM images). (b) elements mapping spectrum and HAADF-TEM of CeNi_{1.6}Fe-MIL-53.



Fig S4. HAADF-TEM and elements mapping spectrum of $Ni_{1.6}$ Fe-MIL-53.







Fig S6. EDS spectrums of (a) $Ni_{1.6}$ Fe-MIL-53, (b) CeNi_{1.6}Fe-MIL-53 and (c) Ce@Ni_{1.6}Fe-MIL-53.



Fig S7. XRD pattern of Fe-MIL-53 and simulated MIL-53.



Fig S8. Crystal structure model of (a) Fe-MIL-53, (b) Ni_{1.6}Fe-MIL-53 and (c) Ce@Ni_{1.6}Fe-MIL-53 (Gray: Ni, Yellow: Fe, Green: Ce, Red: O, Brown: C, Pink: H).



Fig S9. Survey XPS spectrum of Ni_{1.6}Fe-MIL-53, CeNi_{1.6}Fe-MIL-533 and Ce@Ni_{1.6}Fe-MIL-53.



Fig S10. C 1s XPS spectrum of Ni_{1.6}Fe-MIL-53, CeNi_{1.6}Fe-MIL-533 and Ce@Ni_{1.6}Fe-MIL-53.



Fig S11. O 1s XPS spectrum of Ni_{1.6}Fe-MIL-53, CeNi_{1.6}Fe-MIL-533 and Ce@Ni_{1.6}Fe-MIL-53.



Fig S12. Valence spectra of Ni_{1.6}Fe-MIL-53, CeNi_{1.6}Fe-MIL-533 and Ce@Ni_{1.6}Fe-MIL-53.



Fig S13. (a) UV–Vis absorption spectra and (b) Tauc plot curves of $Ni_{1.6}$ Fe-MIL-53, Ce $Ni_{1.6}$ Fe-MIL-533 and Ce@ $Ni_{1.6}$ Fe-MIL-53.



Fig S14. Linear sweep voltammetric OER curves of (a) $Ce_xNi_{1.6}Fe-MIL-53$ and (c) $Ce_x@Ni_{1.6}Fe-MIL-53$ (x = 0.6, 0.8, 1.0, 1.2, 1.4). Over potential and current density of corresponding (b) $Ce_xNi_{1.6}Fe-MIL-53$ and (d) $Ce_x@Ni_{1.6}Fe-MIL-53$ (x = 0.6, 0.8, 1.0, 1.2, 1.4) at 10 mA cm⁻² and 1.5 V vs RHE, respectively.



Fig S15. Tafel plots of (a) $Ce_xNi_{1.6}Fe$ -MIL-53 and (b) $Ce_x@Ni_{1.6}Fe$ -MIL-53 (x = 0.6, 0.8, 1.0, 1.2, 1.4).



Fig S16. CV curves of (a) Ni_{1.6}Fe-MIL-53, (b) CeNi_{1.6}Fe-MIL-53, (c) Ce@Ni_{1.6}Fe-MIL-53 and (d) Fe-MIL-53 at potential of $1.0 \sim 1.1$ V vs RHE from scan rate of 10 mV s⁻¹ ~ 50 mV s⁻¹.



Fig S17. CV curves of (a) $Ce_{0.6}Ni_{1.6}Fe$ -MIL-53, (b) $Ce_{0.8}Ni_{1.6}Fe$ -MIL-53, (c) $Ce_{1.2}Ni_{1.6}Fe$ -MIL-53 and (d) $Ce_{1.4}Ni_{1.6}Fe$ -MIL-53 at potential of $1.0 \sim 1.1$ V vs RHE from scan rate of 10 mV s⁻¹ ~ 50 mV s⁻¹.



Fig S18. CV curves of (a) $Ce_{0.6}$ @Ni_{1.6}Fe-MIL-53, (b) $Ce_{0.8}$ @Ni_{1.6}Fe-MIL-53, (c) $Ce_{1.2}$ @Ni_{1.6}Fe-MIL-53 and (d) $Ce_{1.4}$ @Ni_{1.6}Fe-MIL-53 at potential of $1.0 \sim 1.1$ V vs RHE from scan rate of 10 mV s⁻¹ ~ 50 mV s⁻¹.



Fig S19. Plots of the current density differences vs scan rate for (a) $Ce_xNi_{1.6}Fe-MIL-53$ and (b) $Ce_x@Ni_{1.6}Fe-MIL-53$ (x = 0.6, 0.8, 1.0, 1.2, 1.4) at 1.05 V in the non-Faradic range, respectively.



Fig S20. ECSA and C_{dl} value of (a) $Ce_xNi_{1.6}Fe$ -MIL-53 and (b) $Ce_x@Ni_{1.6}Fe$ -MIL-53 (x = 0.6, 0.8, 1.0, 1.2, 1.4), respectively.



Fig S21. Calculated O₂ TOF values of different electrocatalysts.



Fig S22. EIS Nyquist plots of (a) $Ce_xNi_{1.6}Fe-MIL-53$ and (b) $Ce_x@Ni_{1.6}Fe-MIL-53$ (x = 0.6, 0.8, 1.0, 1.2, 1.4).



Element	Freedom	value	EIIOI	
R1	Free(+)	10.96	N/A	N/A
CPE1-T	Free(+)	0.0016393	N/A	N/A
CPE1-P	Free(+)	0.61586	N/A	N/A
R3	Free(+)	2.443	N/A	N/A
R2	Free(+)	12.69	N/A	N/A
W1-R	Free(+)	7.347	N/A	N/A
W1-T	Free(+)	0.18047	N/A	N/A
W1-P	Free(+)	0.49206	N/A	N/A

Error 0/

Fig S23. Electrochemical fitting circuit and circuit parameters for CeNi_{1.6}Fe-MIL-53.

55, CeNi _{1.6} Fe-MiL-55 and Ce@Ni _{1.6} Fe-MiL-55.				
Element	Catalyst	C-C	C=O	
	Ce@Ni _{1.6} Fe-MIL-53	284.92 eV	288.77 eV	
С	CeNi _{1.6} Fe-MIL-53	284.75 eV	288.70 eV	
	Ni ₁₆ Fe-MIL-53	284.89 eV	288.60 eV	

Table S1. XPS peak types and corresponding binding energies of C 1s in $Ni_{1.6}$ Fe-MIL-53, Ce $Ni_{1.6}$ Fe-MIL-53 and Ce $@Ni_{1.6}$ Fe-MIL-53.

Table S2. XPS peak types and corresponding binding energies of O 1s in $Ni_{1.6}$ Fe-MIL-53, CeNi_{1.6}Fe-MIL-53 and Ce@Ni_{1.6}Fe-MIL-53.

Element	Catalyst	M-OH	M-O	Absorbed H ₂ O	C-0
Ο	Ce@Ni _{1.6} Fe-MIL-53	None	531.78	None	533.24
			eV		eV
	CeNi _{1.6} Fe-MIL-53	531.13	531.71	522 87 N	None
		eV	eV	552.87 CV	
	Ni _{1.6} Fe-MIL-53	531.31	531.72	522 60 aV	Nona
		eV	eV	552.09 C V	None

Table S3. XPS peak types and corresponding binding energies of Ni and Fe 2p in Ni_{1.6}Fe-MIL-53, CeNi_{1.6}Fe-MIL-53 and Ce@Ni_{1.6}Fe-MIL-53.

Element	Catalyst	2p _{3/2}	Satellite-1	2p _{1/2}	Satellite-2
Ni ²⁺	Ce@Ni _{1.6} Fe-MIL-53	856.53 eV	861.99 eV	874.16 eV	881.44 eV
	CeNi _{1.6} Fe-MIL-53	856.28 eV	861.79 eV	873.89 eV	880.29 eV
	Ni _{1.6} Fe-MIL-53	856.33 eV	861.74 eV	874.04 eV	879.98 eV
Fe ³⁺	Ce@Nil.6Fe-MIL-53	712.14 eV	717.62 eV	725.44 eV	732.58 eV
	CeNi1.6Fe-MIL-53	712.52 eV	718.40 eV	725.51 eV	733.42 eV
	Ni1.6Fe-MIL-53	712.33 eV	718.42 eV	725.80 eV	732.79 eV

Table S4. XPS peak types and corresponding binding energies of Ce 3d in CeNi_{1.6}Fe-MIL-53 and Ce@Ni_{1.6}Fe-MIL-53.

	Ce ³⁻	ł	Ce ⁴⁺		
Catalyst	3d _{5/2}	3d _{3/2}	Characteristic peak	3d _{3/2}	
CeNi _{1.6} Fe-MIL-53 (Ce ³⁺ : 43.49%, Ce ⁴⁺ :56.51%)	880.65 eV 891.05 eV	897.65 eV 903.65 eV	873.75 eV	911.35 eV 918.65 eV	
Ce@Ni _{1.6} Fe-MIL-53 (Ce ³⁺ : 49.33%, Ce ⁴⁺ :50.67%)	881.46 eV 887.21 eV	895.67 eV 903.59 eV	874.13 eV	909.67 eV 921.74 eV	

* Only $3d_{3/2}$ peaks are taken into the calculation for accuracy as the $3d_{5/2}$ region is influenced by Ni 2*p* spectra even after the removal of overlapping Ni peaks ³.

Cotoluzta	(Defense	
Catarysis	$\eta_{10}({ m mV})$	Tafel slope (mV dec ⁻¹)	References
CeNi _{1.6} Fe-MIL-53	277	31.03	This work
CSCNF1	277	54.1	4
5%Ce-CoAl LDH@MoS ₂	278	65.7	5
CeO ₂ -Co ₃ O ₄ /CF	285	70	6
Ce-Co(PO ₃) ₂ @NF-1	286	64.3	7
Ce-doped CoMoP/MoP@C	287	74.4	8
NiCeO _x	295	66	9
CeFeCoP/NF	298	114	10
Ce _{0.21} @Co(OH) ₂	300	72	11
$Ce_{0.2}MnFe_{1.8}O_4$	310	31	12
Ce-NiO-E	382	118.7	13
Ce-NiO-L	426	131.6	10
$CeCu_3Ru_4O_{12}$	311	119	14
CeO ₂ /Co ₄ N	318	80	15
CoO-CeO ₂	319	63	16
$\mathrm{Co}_{0.9}\mathrm{Ce}_{0.1}\mathrm{O}_{\mathrm{x}}$	320	104.7	17
NiS/CeS/SSS	289	44	18
CoO/CeO ₂	291	84	10
Ag-CeO ₂ -Co ₃ O ₄ /C	340	130.1	19
$Ce(3)-Co_3O_4$	369	56	20
Ce-CMO-18%	378	86	21
Ir@CeO ₂	379	93.4	22
LCC4	380	80	23
Ce-LaCoO ₃ (5.6%)	450	112	24
20CeO ₂ /Co-Bi	453	120	25

 Table S5. Comparison of activity between Ce@NiFe-MOF-5 and other Ce-doped catalysts.

References

1. C. C. L. McCrory, S. Jung, I. M. Ferrer, S. M. Chatman, J. C. Peters and T. F. Jaramillo, *J. Am. Chem. Soc.*, 2015, **137**, 4347-4357.

 L. Yaqoob, T. Noor, N. Iqbal, H. Nasir, N. Zaman and K. Talha, *J. Alloys Compd*, 2021, 850, 156583.

3. M. Liu, K. A. Min, B. Han and L. Y. S. Lee, *Adv. Energy Mater.*, 2021, **11**, 2101281.

4. C. B. Njoku and R. J. Kriek, *Electrocatalysis*, 2020, 11, 628-641.

5. M. K. Rong, Y. Mo, S. W. Zhou, X. Ma, S. Wang, Z. F. Cao and H. Zhong, *Int. J. Hydrog. Energy*, 2022, **47**, 1644-1655.

6. X. Yang, Z. X. Tao, Y. M. Wu, W. Lin and J. Zheng, *J. Alloys Compd*, 2020, **828**, 154394.

7. Y. Y. Yang, Y. L. Xiong, Q. Zhou, J. Y. Yang, D. L. Qian and Z. A. Hu, *Mater Sci Eng B Solid State Mater Adv Technol*, 2023, **290**, 116344.

 T. Y. Chen, Y. Y. Fu, W. H. Liao, Y. Q. Zhang, M. Qian, H. J. Dai, X. F. Tong and Q. H. Yang, *Energy Fuels*, 2021, **35**, 14169-14176.

9. J. Yu, Q. Cao, Y. B. Li, X. Long, S. H. Yang, J. K. Clark, M. Nakabayashi, N. Shibata and J. J. Delaunay, *ACS Catal.*, 2019, **9**, 1605-1611.

10. L. H. Shen, S. H. Tang, L. M. Yu, Q. K. Huang, T. L. Zhou, S. Yang, H. L. Yu, H.

X. Xiong, M. J. Xu, X. Zhong and L. Zhang, J Solid State Chem, 2022, 314, 123434.

Y. N. Zhou, R. Y. Fan, S. Y. Dou, B. Dong, Y. Ma, W. L. Yu, M. X. Li, Y. L.
 Zhou, C. G. Liu and Y. M. Chai, *J. Energy Chem*, 2021, **59**, 299-305.

12. T. Pandiarajan, S. Ravichandran and L. J. Berchmans, *Rsc Advances*, 2014, 4, 64364-64370.

W. Gao, Z. Xia, F. Cao, J. C. Ho, Z. Jiang and Y. Qu, *Adv. Funct. Mater.*, 2018, 28, 1706056.

14. W. Liu, K. Kawano, M. Kamiko, Y. Kato, Y. Okazaki, I. Yamada and S. Yagi, *Small*, 2022, **18**, e2202439.

15. X. P. Sun, Y. H. Zhang, Y. Xiao, Z. Q. Li, L. Z. Wei, G. Yao, H. L. Niu and F. C.

Zheng, Inorg. Chem., 2022, 61, 14140-14147.

16. X. N. Ren, F. Hou, F. Y. Wang, X. W. Zhang and Q. F. Wang, *Int. J. Hydrog. Energy*, 2018, **43**, 22529-22537.

17. L. L. Pan, Q. Q. Wang, Y. D. Li and C. J. Zhang, J Catal, 2020, 384, 14-21.

H. Z. Liu, H. Duan, J. Yu, C. Qiu, R. X. Yu, J. Q. Gao, S. M. Li, X. J. Du, Z. C.
 Si and S. H. Yang, ACS Mater. Lett, 2022, 4, 2572-2578.

19. T. Li, Z. He, X. Liu, M. Jiang, Q. Liao, R. Ding, S. Liu, C. Zhao, W. Guo, S. Zhang and H. He, *Surf. Interfaces*, 2022, **33**, 102270.

20. J. M. Zhou, H. Y. Zheng, Q. J. Luan, X. B. Huang, Y. Li, Z. S. Xi, G. L. Lu, L.
W. Xing and Y. Q. Li, *Sustain. Energy Fuels*, 2019, 3, 3201-3207.

21. X. Chen, F. Han, X. Chen, C. Zhang and W. Gou, Catalysts, 2022, 12, 1122.

22. M. Akbayrak and A. M. Önal, J. Electrochem. Soc., 2022, 169, 076511.

D. W. Ji, C. H. Liu, Y. H. Yao, L. L. Luo, W. C. Wang and Z. D. Chen, *Nanoscale*, 2021, 13, 9952-9959.

24. J. Qian, T. Wang, Z. Zhang, Y. Liu, J. Li and D. Gao, *Nano Energy*, 2020, 74, 104948.

25. X. M. Zhou, S. J. Guo, Q. R. Cai and S. M. Huang, *Nanoscale Adv.*, 2019, **1**, 3686-3692.